

Experimental Measurements Based

Back Tracking Simulations for Recent OBLA Operations

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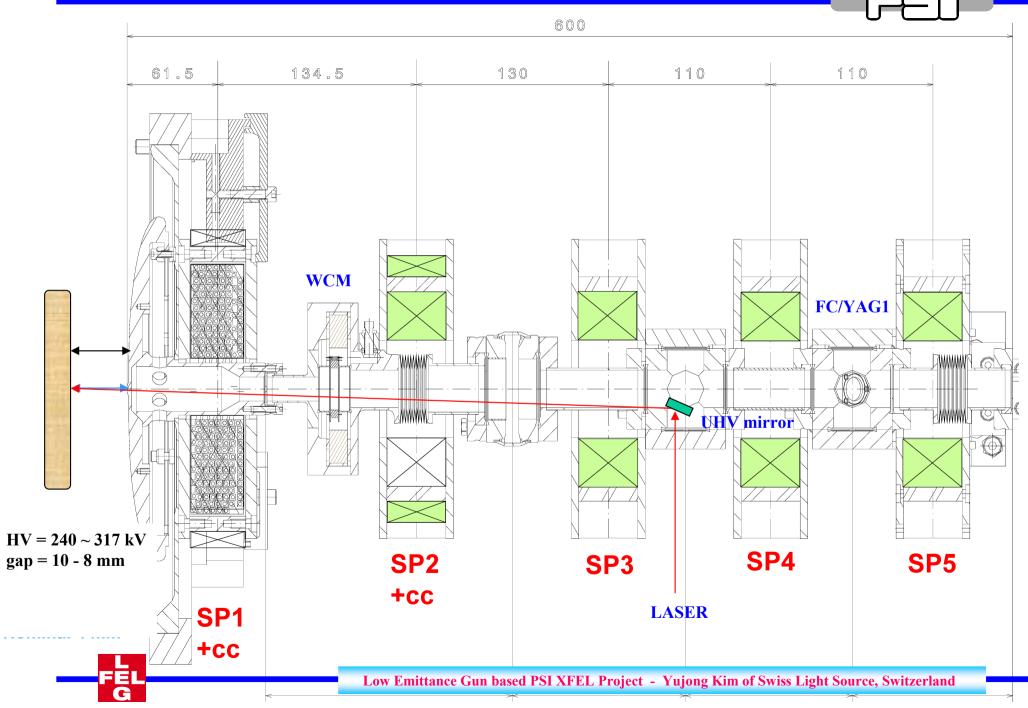
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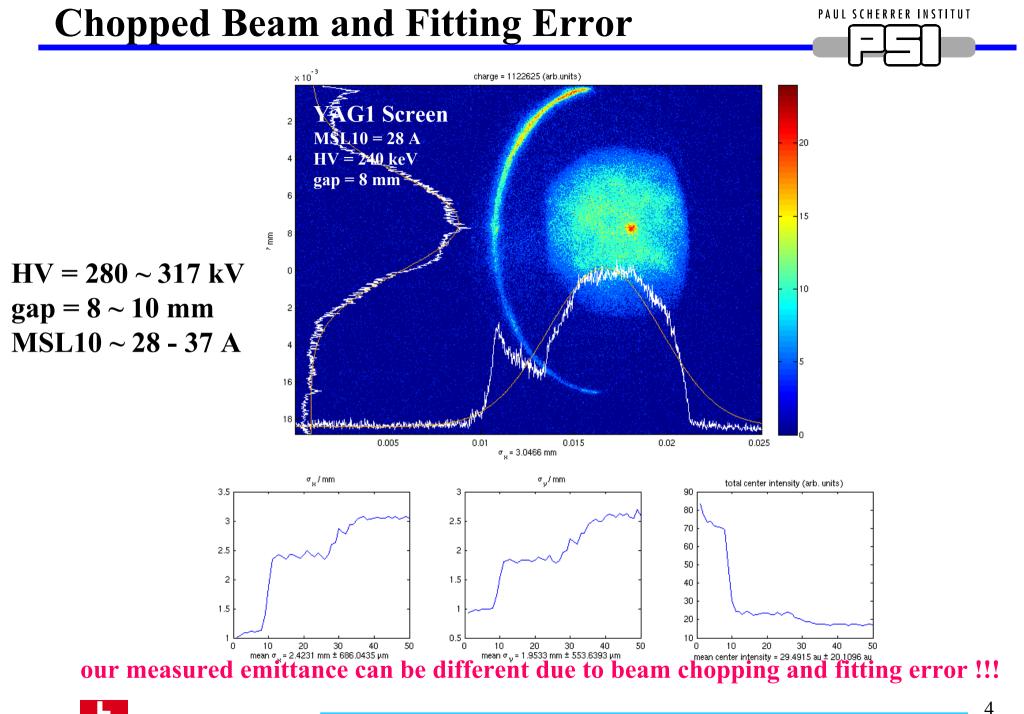
Observed Strange Things during OBLA Operation

- A Strong Back Ground Noise on YAG1 screen
- Difference in Measured Charge at Faraday Cup and Wall Current Monitor
- Charge Dropping at a Lower Beam Energy and Low Solenoid Currents.
- **ASTRA Simulation Results**
 - Back Tracking Method
 - Beam Chopping Simulation & Solution on Recent Operations
- **Cross-checking with Experiments**
 - Beam Chopping Checking at 280 keV
 - Beam Chopping Checking at 317 keV
- □ Summary and Acknowledgements



Layout of OBLA





C

Charge Difference Between FC & WCM

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gap voltage = 280 kV (low beam energy, we can not apply strong focusing)
gap = 10 mm
MSL10 = from 27 A to 36 A with 1 A step.
all other magnets = 0 A

MSL10 current	Charge at FC		Charge at WCM
36 A	13.7 рС	over focusing	
35 A	15.5 pC	^	
34 A	15.6 pC		
33 A	15.8 pC		~ 16 pC
32 A	15.5 pC		
31 A	15.26 pC		
30 A	14.18 pC		
29 A	11.44 pC		
28 A	9.1 pC	Ļ	
27 A	7.22 pC	weak focusing	

Measured on Feb. 20th, 2008



Back Tracking Simulation Method

For realistic simulations, we used all measured data for Back Tracking:

Measured gap voltage Measured solenoid fields Measured charge from Faraday cup Measured laser pulse length & profile (assumed uniformed Gaussian) Measured laser profile (assumed uniform Gaussian) Measured beam size on YAG1 screen to estimate laser beam size on cathode (Back Tracking)



Measured RMS Beam Size

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For realistic simulations, we used all measured data for Back Tracking **Operation conditions on Feb 22nd, 2008**

Beam kinetic energy = 240 keVMSL10 = 29 ALaser long profile = Gaussian

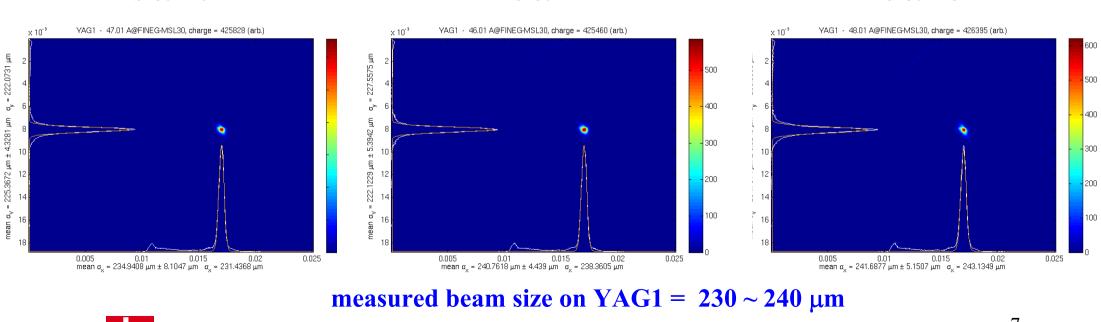
MSL30 = 46 A

Gap size = 8 mm MSL30 = 46 - 48 A

Charge = 12 pC Used screen = YAG1 Laser rms length = 6.5 ps Laser trans. profile = Gaussian

MSL30 = 48 A

Estimated laser rms size $\sim 53.75 \ \mu m$ from back tracking and measured one.



MSL30 = 47 A



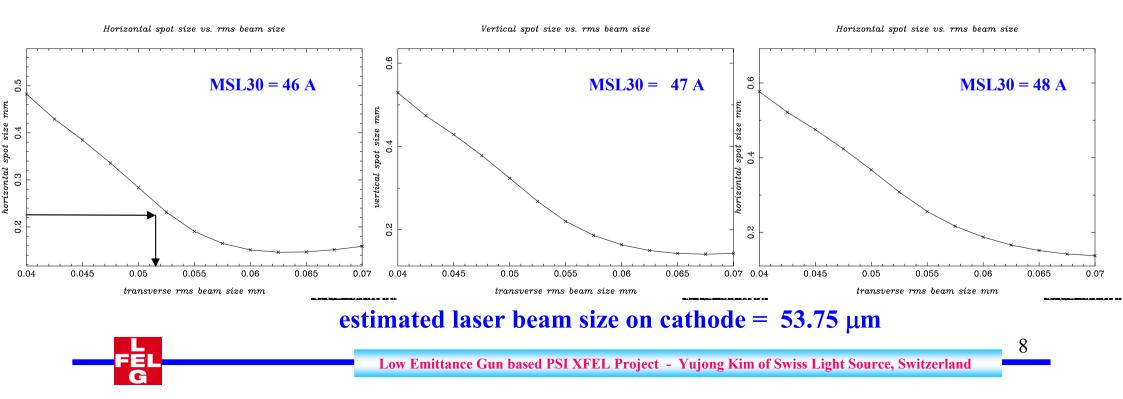
ASTRA Back Tracking on RMS Laser Size

For realistic simulations, we used all measured data for Back Tracking Operation conditions on Feb 22nd, 2008

Beam kinetic energy = 240 keV MSL10 = 29 A Laser long profile = Gaussian Gap size = 8 mm MSL30 = 46 - 48 A Laser rms length = 6.5 ps Charge = 12 pC Used screen = YAG1 Laser trans. profile = Gaussian

Estimated laser rms size \sim 53.75 μ m from back tracking and measured one.

ASTRA Back Tracking Simulation on rms laser size Vs. MSL30 current



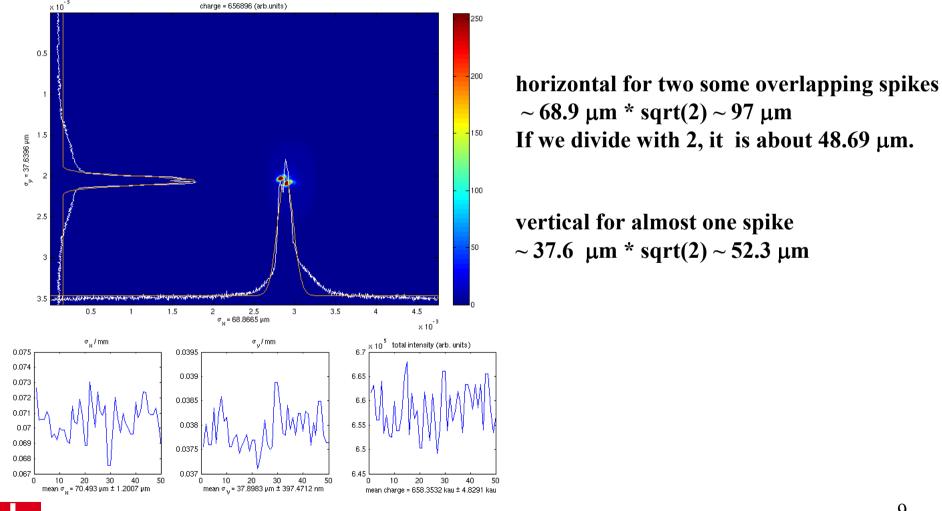
Measured Laser Profile on Virtual Cathode PAUL SCHERRER INSTITUT

Well agreed with Simulation & Measurements !!!

From e-logbook on Feb. 21, 2008

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Note that we have to multiply a missing factor sqrt(2) in this measured value We fixed this bug in Matlab ShowImage tool from Feb. 22th, 2008.

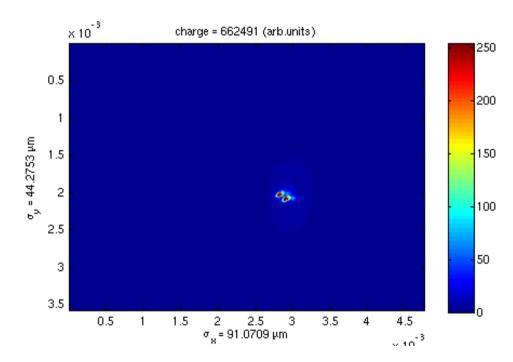


Measured Laser Profile on Virtual Cathode

Well agreed with Simulation & Measurements !!!

From e-logbook on Feb. 21, 2008

Note that we have to multiply a missing factor sqrt(2) in this measured value We fixed this bug in Matlab ShowImage tool from Feb. 22th, 2008.



horizontal for two some overlapping spikes $\sim 91.1 \ \mu\text{m} * \text{sqrt}(2) \sim 129 \ \mu\text{m}$ If we divide with 2, it is about 64 μm .

vertical for almost one spike $\sim 44.2 \ \mu m * sqrt(2) \sim 62.6 \ \mu m$

When we used a different Matlab tool for the same laser profile, measured laser beam size was slightly larger than that at previous page. Therefore, if we apply average for two cases, it is close to 56 μ m for horizontal and it is close to 57.6 μ m for vertical. These sizes are very close to our estimated value with the backing tracking simulation.



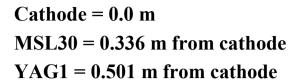
ASTRA Simulations on Recent Operations

For realistic simulations, we used all measured data for Back Tracking

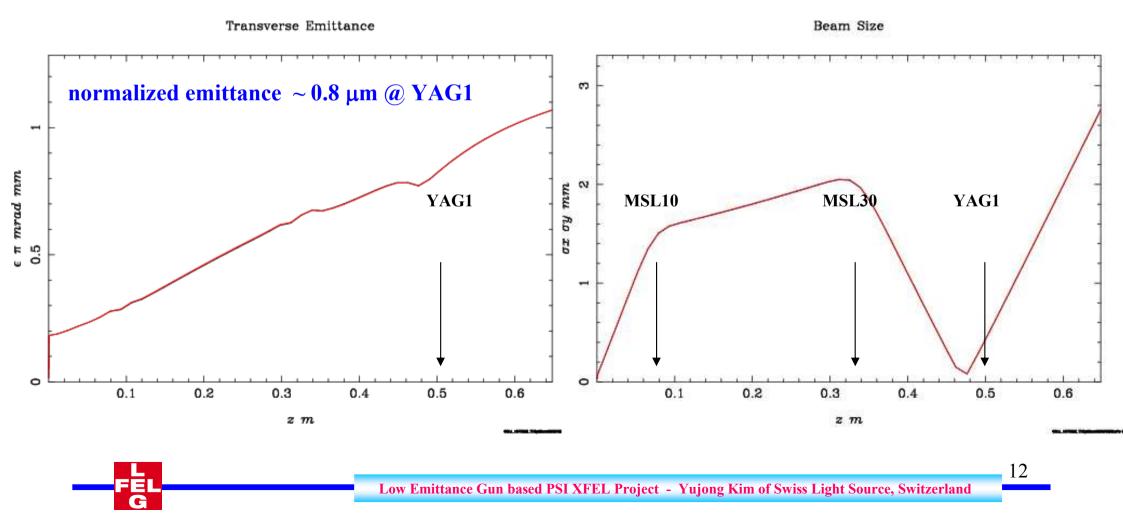
Operation conditions on Feb 19th, 2008

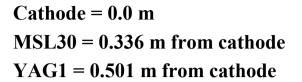
Beam kinetic energy = 292 keV Gap size = 10 mm Charge = 12 pC MSL10 = 28 A MSL30 = 58 A Used screen = YAG1 Laser long profile = Gaussian Laser rms length = 6.5 ps Laser trans. profile = Gaussian Laser rms size ~ 54 μm (comes from back tracking and measured one).



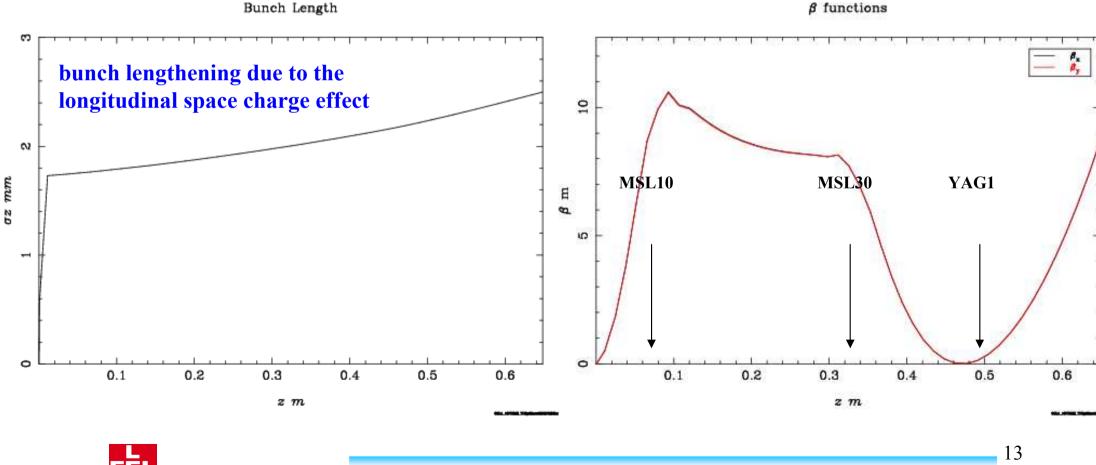


MSL10 = 0.0715 m from cathode MSL40 = 0.446 m from cathode MSL50 = 0.556 m from cathode



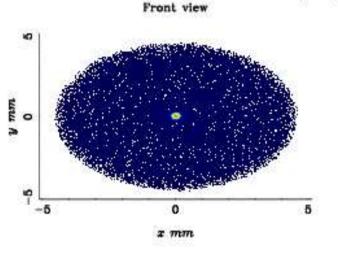


MSL10 = 0.0715 m from cathode MSL40 = 0.446 m from cathode MSL50 = 0.556 m from cathode

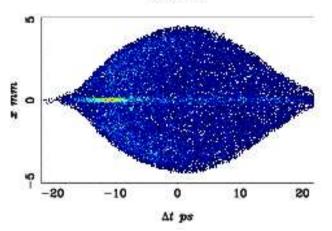


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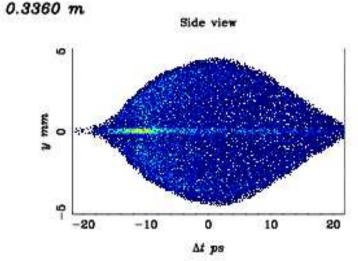
Cathode = 0.0 m MSL30 = 0.336 m from cathode YAG1 = 0.501 m from cathode







MSL10 = 0.0715 m from cathode MSL40 = 0.446 m from cathode MSL50 = 0.556 m from cathode



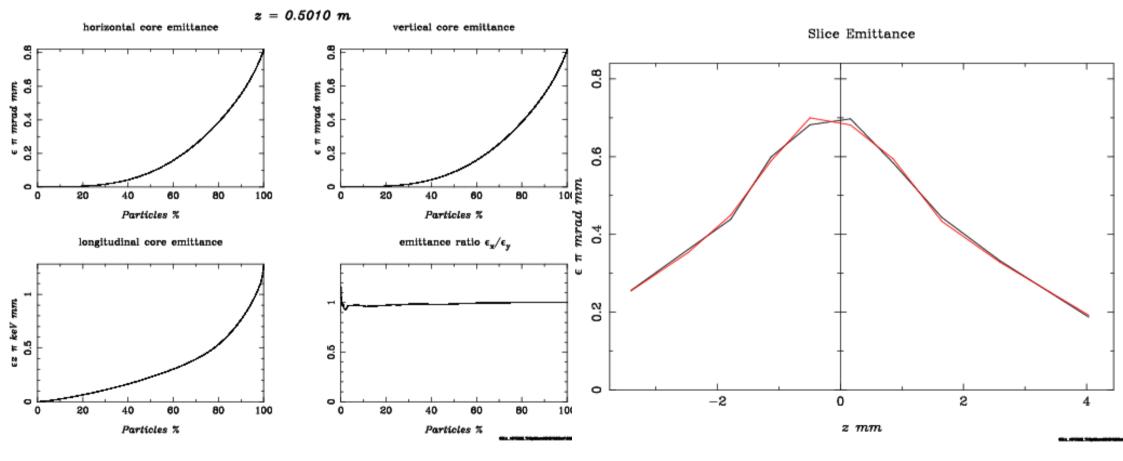
Beam @ MSL30 Before UHV mirror

at core region, all electron beams are concentrated !!! And beam wings are very wide ~ 5 mm !!! One of part of wing can be chopped by the UHV mirror.

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Cathode = 0.0 m MSL30 = 0.336 m from cathode YAG1 = 0.501 m from cathode MSL10 = 0.0715 m from cathode MSL40 = 0.446 m from cathode MSL50 = 0.556 m from cathode

At YAG1 screen

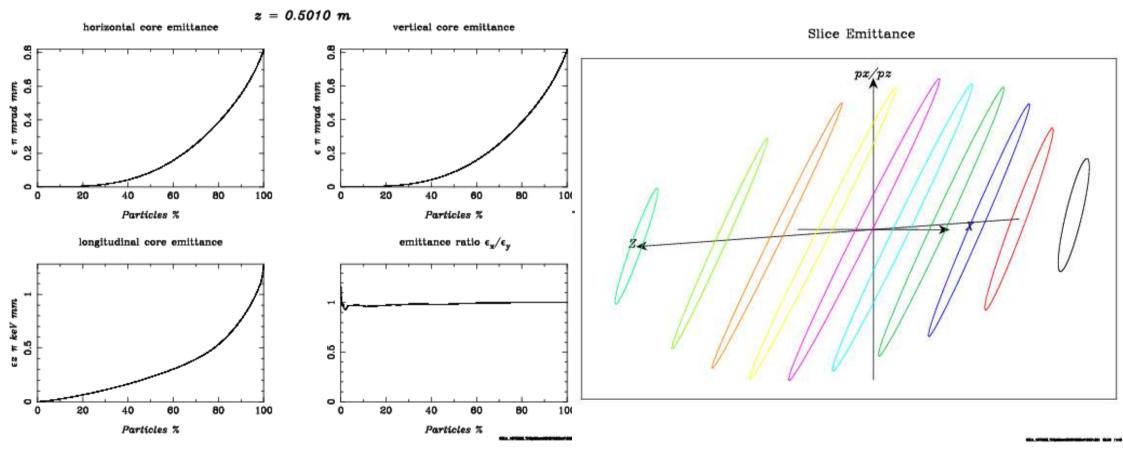




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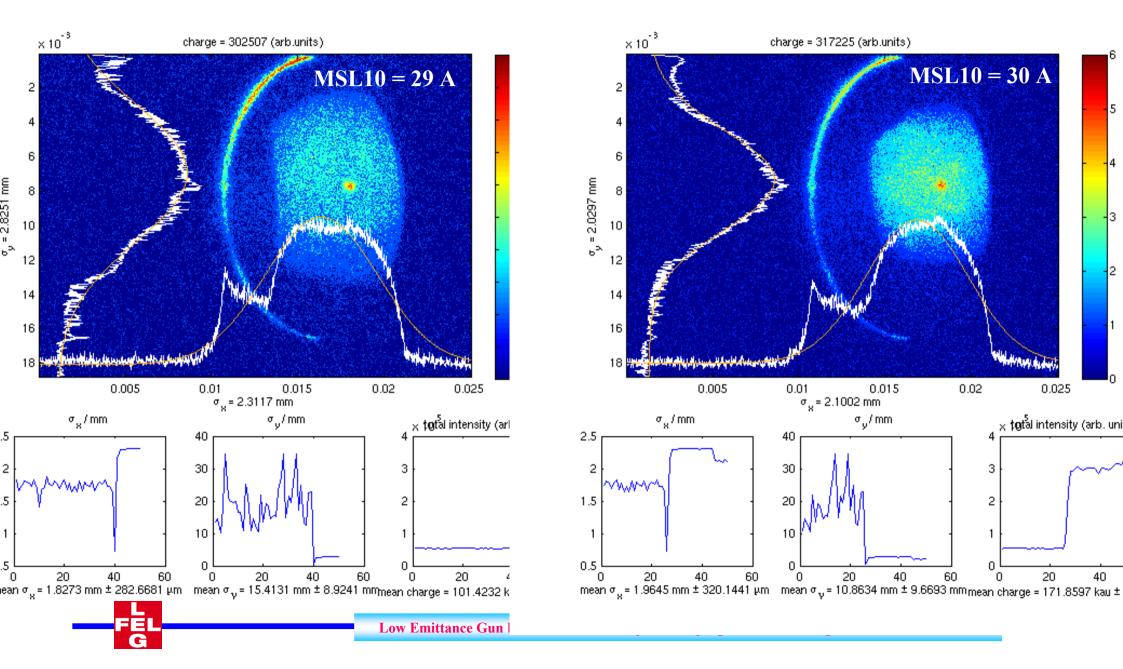
Cathode = 0.0 m MSL30 = 0.336 m from cathode YAG1 = 0.501 m from cathode MSL10 = 0.0715 m from cathode MSL40 = 0.446 m from cathode MSL50 = 0.556 m from cathode

At YAG1 screen

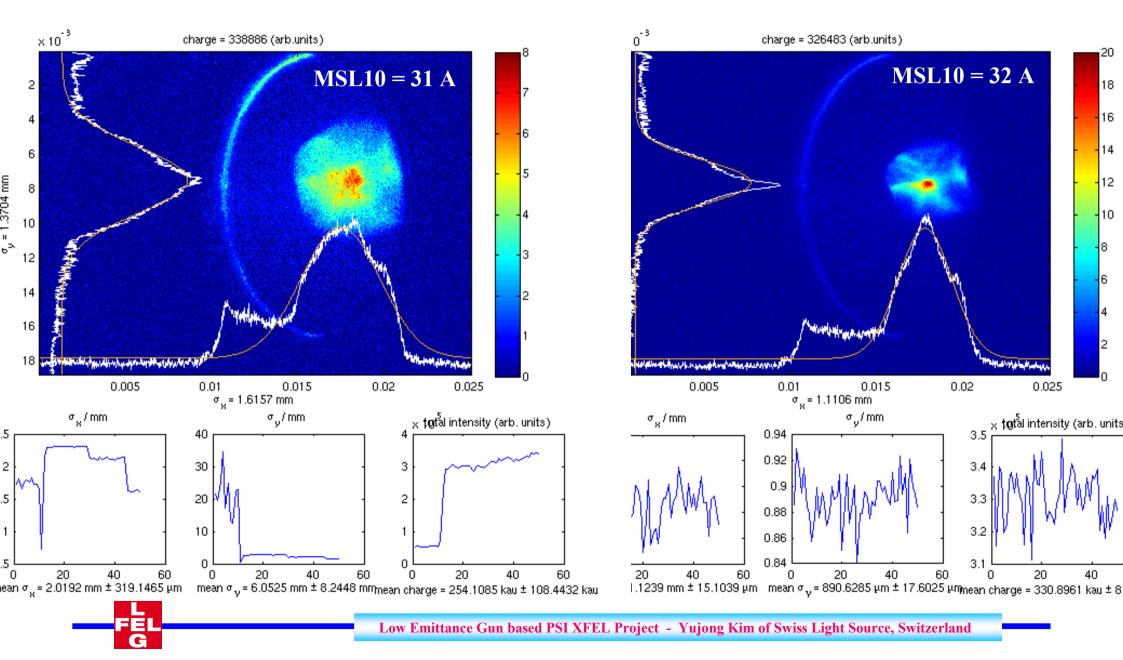




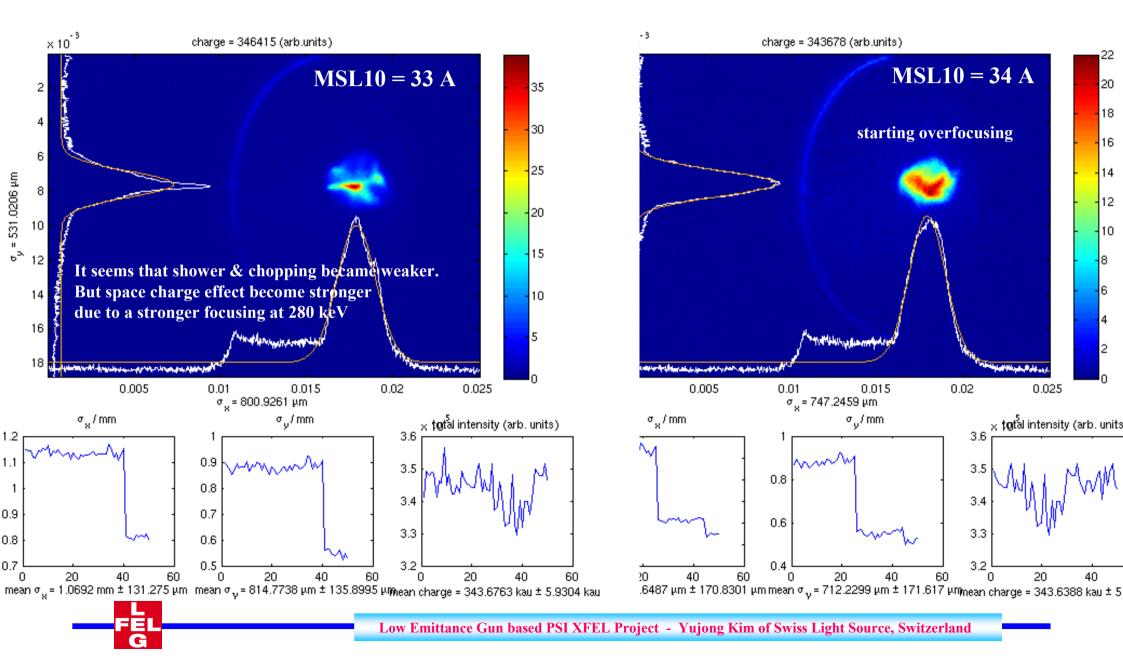
gap voltage = 280 kV, gap = 10 mm, MSL10 = from 27 A to 36 A with 1 A step, all others = 0 A



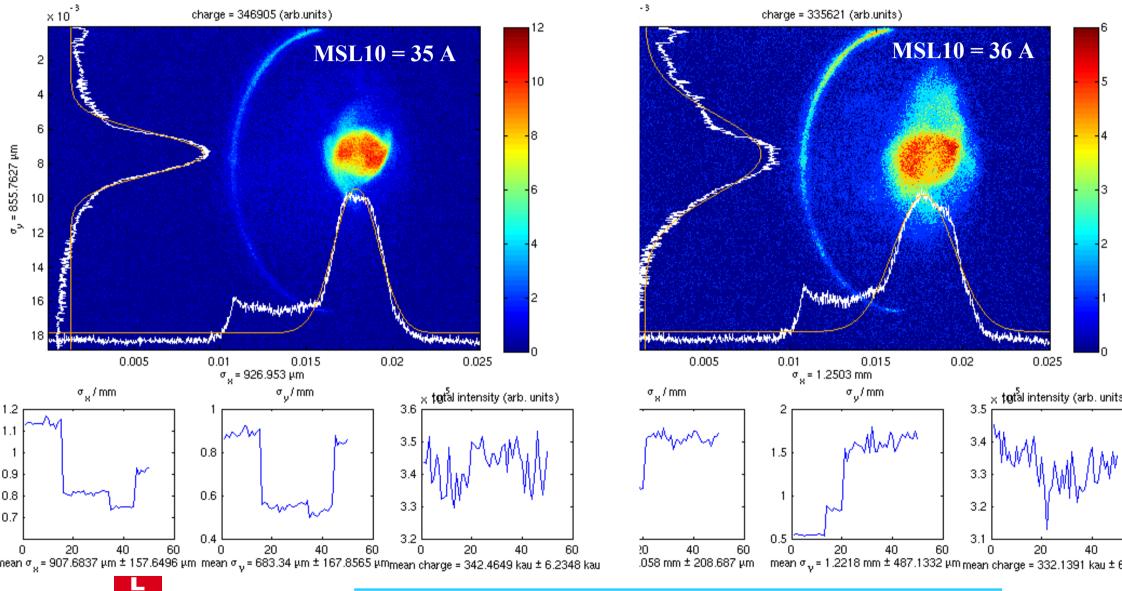
gap voltage = 280 kV, gap = 10 mm, MSL10 = from 27 A to 36 A with 1 A step, all others = 0 A



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4.5

3.5

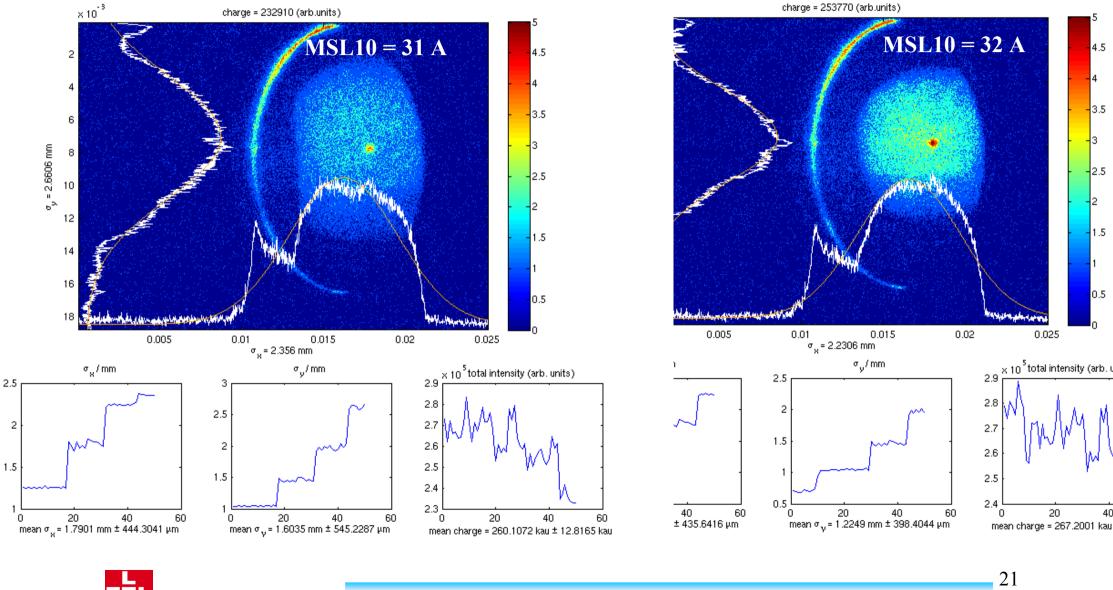
2.5

2

1.5

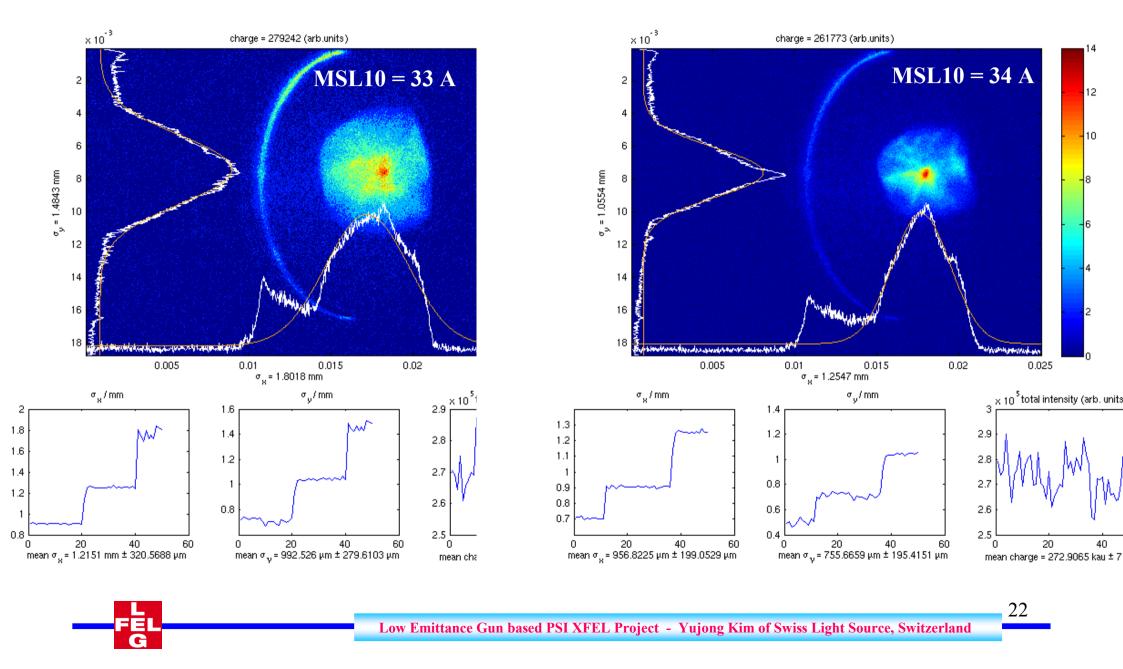
0.5

gap voltage = 317 kV, gap = 10 mm, MSL10 = from 27 A to 36 A with 1 A step, all others = 0 A



Low Emittance Gun based PSI XFEL Project - Yujong Kim of Swiss Light Source, Switzerland

gap voltage = 317 kV, gap = 10 mm, MSL10 = from 27 A to 36 A with 1 A step, all others = 0 A



Simulation for Operation on Feb. 20th



gap volatge ~ 317 kV

Q~17.6 pC

gap = 10 mm

MSL10 = 34.81 A

 $MSL30 = 35 \sim 70 A$

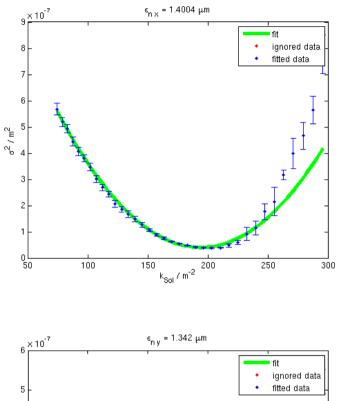
H steerer = 0.32 A

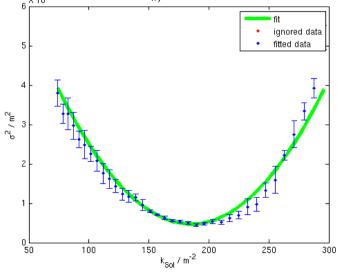
V steerrer = 0.35 A

Used screen = YAG1

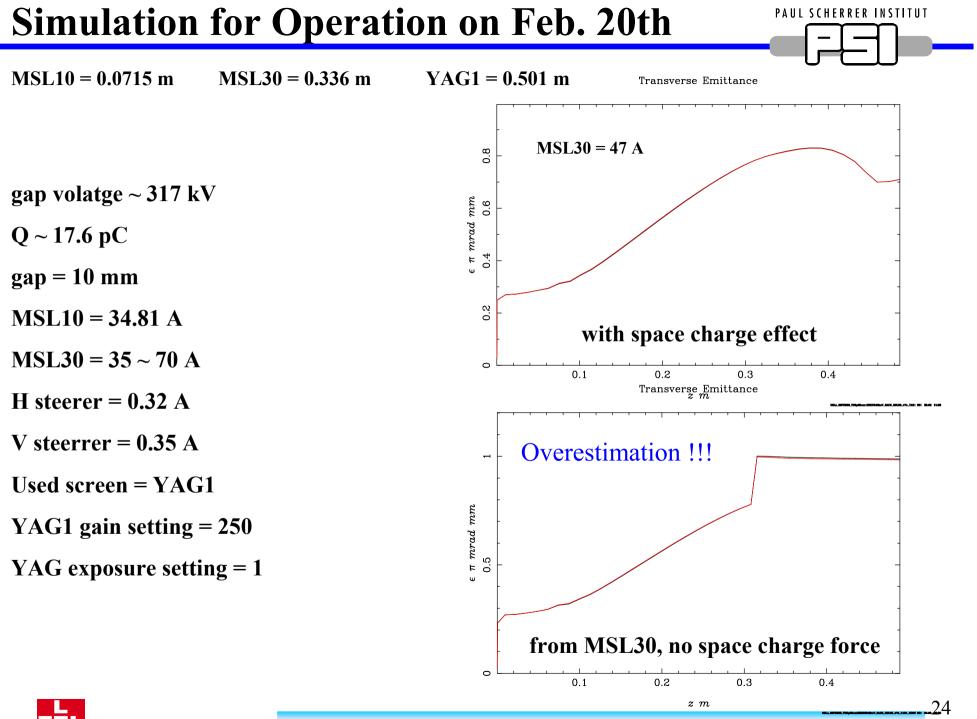
YAG1 gain setting = 250

YAG exposure setting = 1

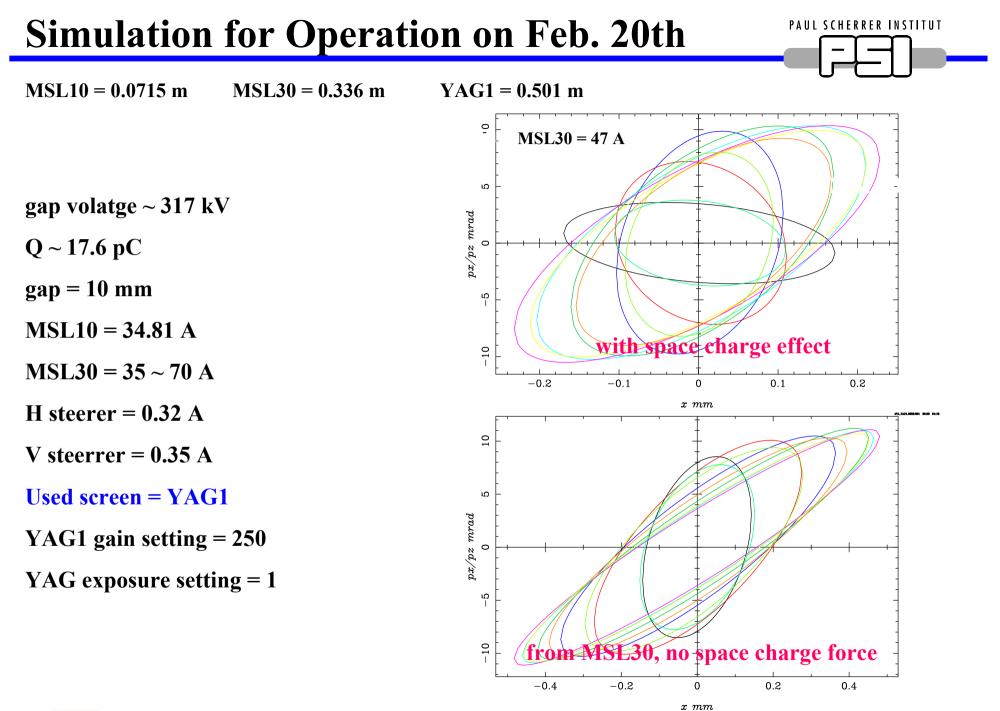








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FEL G

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Optimization on Feb. 20th Operation



gap volatge ~ 317 kV

Q~17.6 pC

gap = 10 mm

MSL10 = 34.81 A

MSL30 ~ 31.8 A

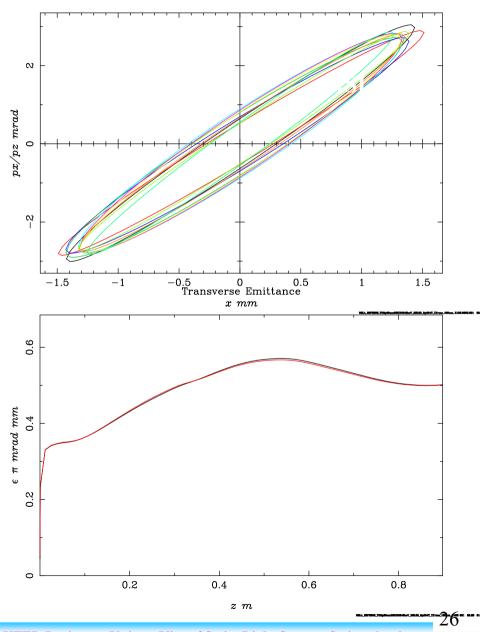
H steerer = 0.32 A

V steerrer = 0.35 A

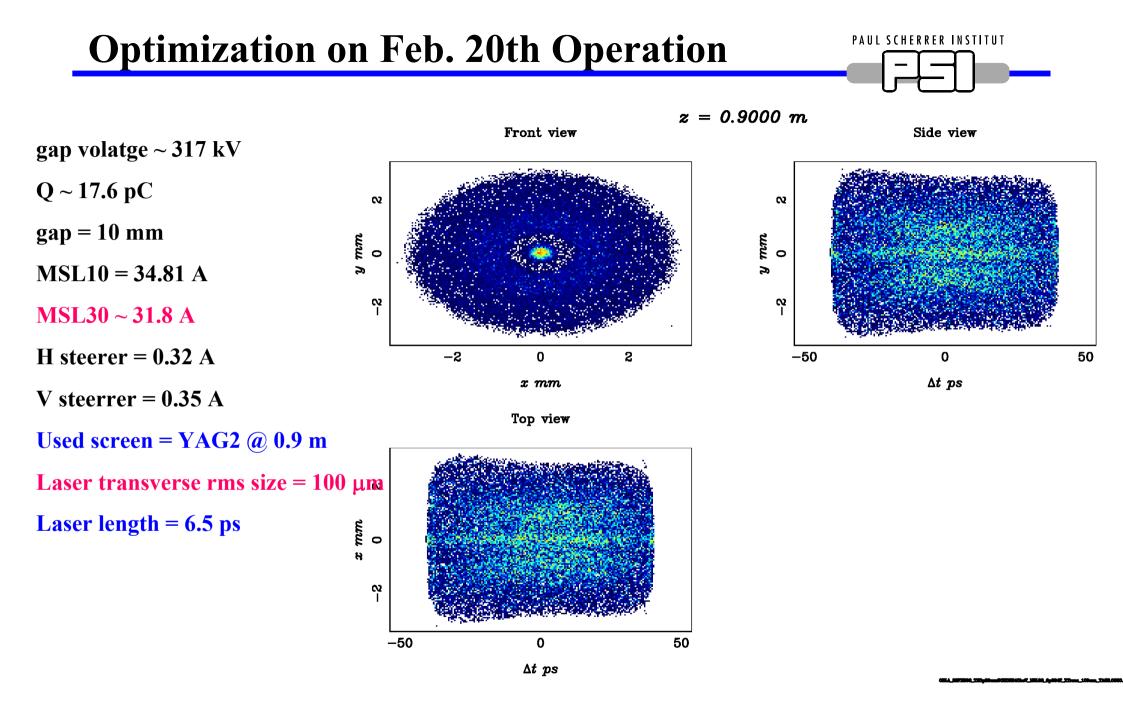
Used screen = YAG2 @ 0.9 m

Laser transverse rms size = $100 \ \mu m$

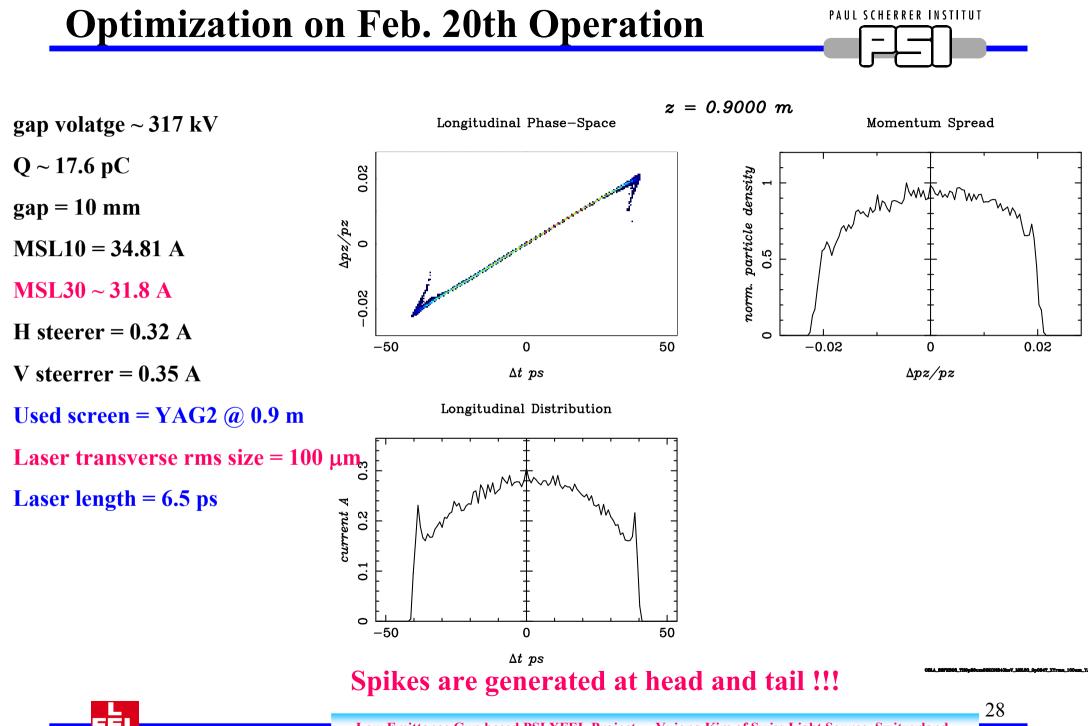
Laser length = 6.5 ps









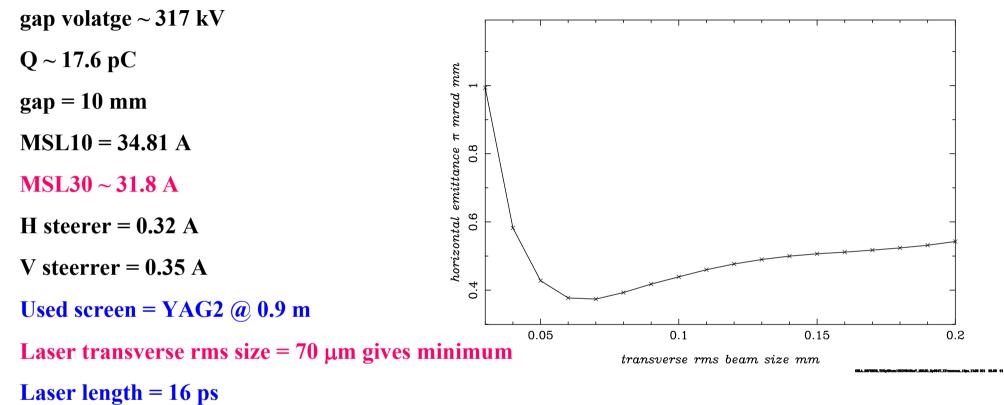


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Optimization on Feb. 20th Operation

Horizontal emittance vs. rms beam size

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a laser with a longer length of 16 ps & a bigger spotsize of around 70 μm gives a better emittance at the moment (at 300 keV range) !!!



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It seems that there are beam chopping by the UHV mirror. But we can not apply too strong focusing due to a lower beam energy (hence stronger space charge force).

When a big chopping is generated, there is a shower and background on YAG1 screen. Due to the background, we met a fitting error in estimating beam size. Therefore, our measured emittance can be different.

We have to optimize laser spotsize and length to reduce space charge force at a lower beam energy.

At the moment, it seems that a round chopping at the right side of YAG1 screen is generated due to misalignment of screen.

Y. Kim sincerely thank Dr. Andreas Adelmann, Dr. Andreas Streun, and Dr. Marco Pedrozzi for their encouragement for OBLA study.

